



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#157  
Amato  
A. Ford  
7/14/03

Applicants: Lin

Docket No.: 2001 P 14585 US

Serial No.: 10/059,321

Art Unit: 2812

Filed: January 31, 2002

Examiner: Stanetta D. Isaac

Title: Reduction of Negative Bias Temperature Instability in Narrow Width PMOS  
Using F2 Implantation

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

RESPONSE UNDER 37 CFR 1.111

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's  
Office Action mailed March 13, 2003. Please amend the above-referenced application as  
follows.

P